



**PATENT APPLICATION**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Hiroyuki NAGASAKA

Group Art Unit: 2882

Application No.: 10/589,962

Examiner: C. RIDDLE

Filed: August 18, 2006

Docket No.: 128675

For: EXPOSURE METHOD, EXPOSURE APPARATUS, EXPOSURE SYSTEM AND  
DEVICE MANUFACTURING METHOD

**REQUEST FOR RECONSIDERATION**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Claims 1, 3-12, 14-23, 26-30 and 40-42 are pending in this application. In reply to the January 20, 2011 Office Action, Applicant respectfully requests reconsideration of the pending claims at least in light of the following remarks.

The Office Action rejects claims 1, 3, 6-12, 14, 19-23, 26, 27 and 30 under 35 U.S.C. §103(a) over Ozawa et al. (U.S. Patent No. 5,739,898) in view of Fujishima et al. (JP 2000-058436<sup>1</sup>). Applicant respectfully traverses the rejection.

Claim 1 recites "a wavelength of said exposure light that enters said space for said at least one exposure is the same as a wavelength of said exposure light that enters said space for said another exposure." The Office Action admits that Ozawa fails to disclose these

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<sup>1</sup> The Office Action includes a typographical error that indicates that Fujishima is JP 2000-057436.